## **Spincoater**

The Development and the commercialization of the Mask Aligner for wafer Midas System will continue to grow along with the value creation for our customers.



## MIDAS Spin Developer SPIN-4000A



The MIDAS Spin Developer system is good for research and variable process of all applications. It represents next generation of full-field coating systems.



ITEM	SPECIFICATIONS
Substrate Size	up to 8" diameter
Max. rotation speed	100 ~ 7000rpm, AC motor
RPM Uniformity	1%
Dispenser nozzle	1. Developer 2. D.I water 3. N2
Dimension(mm)	650×950×1200, Weight: 100Kg



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